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3/23/02  
H3 PATENT

J1017 U.S. PRO  
10/039507  
10/26/01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Nicholas F. Borrelli, Thomas P. Seward III,  
and Charlene M. Smith

Serial No. : Not Yet Assigned

Filed : Simultaneously Herewith

For : SILICA WITH LOW COMPACTION UNDER HIGH  
ENERGY IRRADIATION

COPY OF PAPERS  
ORIGINALLY FILED

Commissioner of Patents and Trademarks  
Washington, D.C. 20231

INFORMATION DISCLOSURE STATEMENT

In accordance with 37 CFR §1.56 and 37 CFR §1.97(b)(1), applicants wish to call the Examiner's attention to the references listed on the Modified 1449 Form submitted herewith.

Pursuant to 37 CFR §1.98(d), copies of the references on the 1449 Form are not being submitted herewith since each of the references was previously cited by or submitted to the Patent Office in prior application No. 09/254,114 filed February 25, 1999, from which this application claims priority under 35 U.S.C. §120. However, if for any reason, the Examiner believes it is necessary or desirable for applicants to provide copies of all or some of these references, the Examiner is requested to advise the undersigned attorney and any copies required will be provided.

The Examiner is respectfully requested to initial a copy of the Modified 1449 Form and return it to applicants to indicate consideration of

the references listed thereon in connection with the prosecution of this application.

Respectfully submitted,

Date: 10/26/01

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